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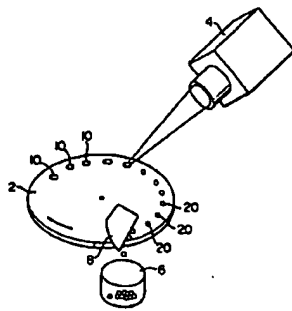
㉖ METHOD OF MANUFACTURING MINUTE METALLIC BALLS UNIFORM IN SIZE

㉗ A method of manufacturing minute metallic balls
 (20) uniform in size comprising the steps of making
 short pieces (18; 10) of metallic wire by cutting a
 fine metallic wire (1) to a given length and shaping

said pieces into balls by heating and melting them at
 a temperature higher than the melting point of said
 metal.

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FIG. 20



in such a manner as to feed such wire without any bend.

Thus, one of the critical features of the present invention resides in that wire-like metal wires are precisely cut at a constant length.

Another critical feature is that the chips cut from the wire-like metal wires are heated to a temperature above the melting point of the metal. A description will be given of this critical feature. In general, molten metal exhibits a large surface tension, so that a fine solid metal heated to a temperature above the melting point naturally tends to form a sphere. From a theoretical point of view, therefore, it is possible to form a metal sphere by preparing a metal solid of the same mass as that of the sphere to be formed, melting the metal solid and then slowly cooling the melt to allow it to solidify.

Needless to say, there is a limit in size at which the force of gravity exceeds the surface tension to thereby make the sphere to have a flattened form. Flattening by the force of gravity, however, does not cause any problem in the invention because the influence of the force of gravity is materially negligible due to extremely small size of the sphere, e.g., 0.5 mm or smaller.

The present inventors have made an intense study to develop a method which would enable an efficient production of fine metal spheres by using the above-described principle, and succeeded in developing a method for producing metal spheres in a practical industrial use. As a result, the inventors have found that the following conditions (1) to (6) are most critical.

(1) Sphere of a constant size is obtainable if the volume of the material placed is constant, even when the material pieces have irregular forms. The use of a wire as a blank material is therefore preferred because it enables an easy preparation of a large quantity of material pieces of a constant mass. Namely, a large quantity of material pieces of a mass can easily be prepared simply by cutting a wire of a constant pitch, provided that the wire has a constant cross-sectional area. The cross-sectional area is preferably maintained to minimize any fluctuation in the mass caused by error in the cutting length and, hence, to further enhance the dimensional precision.

(2) When a wire is used as the blank material, it is necessary that the ratio of the length of the chip cut from the wire to the cross-sectional size of the same is carefully selected because, when the ratio is too large, the chip may be divided into two metal spheres when motion by heating. Although the metal wire chip preferably has a large length while the cross-sectional size is minimized from the view point of the condition

(1) above, it is preferred that the above-mentioned ratio falls within a certain range, constituting the second condition, i.e., formation of one metal sphere from one wire chip. Through an intense study, the inventors have found that the tendency for the metal wire chip to be divided into two spheres is reduced to a satisfactory level when the length of the metal wire chip does not exceed 100 times the diameter of the same, when the blank wire has a circular cross-section. Taking into account also the dimensional tolerances, therefore, it is preferred that the ratio of the length to the diameter of the metal wire chip ranges between 6 and 100, and more preferably between 8 and 60.

(3) It is necessary that adjacent metal wire chips have to be spaced by a minimum distance during melting, for otherwise motion chips may merge in each other to form a greater sphere than expected. In addition, the metal wire chips may be destroyed by application of heat. In order to avoid such a problem, it is necessary that the metal wire chips are spaced by a predetermined distance, hereinafter 1 mm or greater.

(4) The surfaces of the metal wire chips may be oxidized or part of the chip may be dissipated by evaporation during the heating. This causes undesirable effects such as reduction of the yield due to contamination of the bump surface which is strictly required to be clean. It is therefore necessary to take a suitable self-oxidation measure for certain kinds of metal. When the metal used has a high vapor pressure, it is also necessary that the melting is conducted in an atmosphere of an inert gas so as to prevent evaporation.

(5) The temperature to which the metal wire chip is heated only needs to be higher than the melting point. Heating to an unnecessarily high temperature is preferably avoided in order to prevent any change in the metal composition or degradation of the bump surface. The inventors have confirmed that the heating temperature is preferably 0 to 100°C higher than the melting temperature of the metal. To be more precise, it is preferred that the heating temperature is selected to be low when the size of the metal sphere to be obtained is small. When heating to a comparatively high temperature to use a small sphere, it is necessary to minimize the period in which the metal wire chip is held at such a high temperature, thereby preventing evaporation. In such a case, it is also preferred that the rate of cooling to re-solidification is increased to prevent growth of coarse dendrite, thereby preventing degradation of the surface state.

BRIEF DESCRIPTION OF THE DRAWINGS

TECHNICAL FIELD

The present invention relates to a method of efficiently producing, with high degree of uniformity in size, the metal spheres such as bumps which are used as bonding material in bonding methods such as TAB (Tape Automated Bonding) method or flip-chip bonding method which are used in the field of semiconductor packaging.

BACKGROUND ART

TAB method and flip-chip methods are known as semiconductor packaging techniques which make use of bumps. Metals such as gold are used as the material of bumps. Various shapes of bumps are used such as spherical forms, rectangular parallelepiped forms and torus-like structures between the spherical and rectangular parallelepiped forms. Functions of the bumps are to electrically and mechanically bond two opposing electrical members. In general, the bump is placed between these two members in alignment and then heat and pressure are applied to the bump so as to bond these two members. The bump, when considered from the above-mentioned function, preferably has a spherical shape which is easy to deform. Actually, however, bumps have rectangular parallelepiped shapes in most cases. This is because that bumps of parallelepiped shapes can easily be produced by plating or etching, so that the use of bumps of such shapes are used although they are rather inconvenient to use. Plating is the most popular method for forming bumps. This method, however, involves a process to treat the purity and composition of the metal used as the material of the bump are undeniably limited. In addition to the above-mentioned problem concerning the shape.

Formation of a bump by plating is conducted after by directly plating the electrode of an IC by a bump metal which is in most cases gold of a high purity, or by forming a bump on a glass substrate by plating and then transferring the same to the end of the lead on a TAB tape.

The formation of bumps by plating, however, requires an equipment of a large scale and, in addition, suffers from restrictions in the metal composition as stated above. In particular, the first-mentioned plating method which relies upon direct plating on IC chip electrodes impairs the yield of the IC chip products since the IC chips have to undergo the plating process.

As stated before, bumps of spherical shapes have not been used popularly, although the spherical shape is preferred from the view point of function. This fact is entirely attributable to difficulty encountered in the production of the metal sphere with a high degree of uniformity in size.

Various methods have been proposed and used for forming the metal spheres such as water distribution, gas distribution, vacuum distillation, centrifugal distillation, roller distillation, aqueous distillation, and so forth. The water distillation, however, is disadvantageous in that the metal spheres formed by this method are irregular in shape. The gas distribution method is also disadvantageous in that it cannot produce fine spheres.

The centrifugal method is suitable for producing comparatively fine spheres on an industrial scale. As described in Journal of Metals, January 1987, pp. 13-18, however, the metal spheres formed by this method has a rather wide size distribution of 30 to 200 μm. In order to use metal spheres formed by this method as bumps, it is necessary to select only spheres of a specified size suitable for this purpose, by subjecting the formed spheres to, for example, sieving. Sieving the spheres is an industrial scale method which reduces the yield and, hence, is quite impractical. These are the reasons why no positive attempt has been made to put spherical bumps into industrial use.

DISCLOSURE OF THE INVENTION

Accordingly, an object of the present invention is to establish a method which enables an efficient production of the metal spheres with high degree of uniformity in size and shape so as to enable these spheres directly as bumps in semiconductor packaging process, without suffering from restriction in purity and composition of the sphere material and without necessitating any classification such as sieving.

To this end, according to the present invention, there is provided a method of producing the metal spheres with a high degree of uniformity in size, having the steps of cutting an ultra-fine metal wire into chips of a predetermined length, and heating the chips to a temperature higher than the melting point of the chip thereby spherulizing the chips.

One of the most critical requirements for producing bumps with a uniform size is to cut the ultra-fine metal wire exactly at a constant length. Obviously, the precision of the cutting length can be enhanced by restraining the diameter of the ultra-fine wire and selecting a comparatively large cutting length. In general, a bump has an extremely small size, e.g., 100 microns or lower in diameter. The cutting length is usually 0.5 mm or less and 1 mm at the largest, however the wire diameter may be reduced. In addition, metals suitable for use as a bump material are usually soft so that ultra-fine wires formed from such metals are easily deformed by, for example, the force of gravity. Ultra-fine wires of such soft metals are extremely non-rigid, so that a difficulty is encountered in heating the wire

Fig. 1 is an illustration of a first embodiment of the method in accordance with the present invention, showing chips cut from a fine metal wire and arrayed on rows on a flat bottom of a crucible.

Figs. 2A and 2B are illustrations of processes for cutting a wire into a large quantity of chips of a predetermined length.

Fig. 3 is a graph showing distribution of size measured on metal spheres produced in accordance with the first embodiment.

Fig. 4 is a schematic illustration of a cutting step in a second embodiment of the present invention.

Fig. 5 is a schematic illustration of a modification of the second embodiment.

Fig. 6 is a schematic illustration of another modification of the second embodiment.

Figs. 7, 8a and 8b are illustrations of a cutting operation in a third embodiment of the present invention.

Figs. 9a to 9f are illustrations of a cutting operation in a fourth embodiment of the present invention.

Fig. 10 is an illustration of a modification of the cutting operation shown in Figs. 9a to 9f, obtained by replacing a part of the device of Figs. 9a to 9f with an alternative.

Fig. 11 is a schematic illustration of another modification which employs feed rolls.

Fig. 12 is an illustration of a further modification which is improved to provide a higher cutting efficiency.

Fig. 13 is a schematic illustration of a cutting device used in a fifth embodiment of the present invention.

Fig. 14 is a schematic diagrammatic enlarged view of the cutting device of Fig. 13, showing particularly a cutting roller cutting a fine metal wire.

Fig. 15 is an enlarged schematic illustration of a roller in a modification of the cutting device used in the fifth embodiment.

Fig. 16 is an enlarged schematic illustration of a roller in another modification of the cutting device used in the fifth embodiment.

Fig. 17 is a schematic illustration of a device which is used in a heating step in a sixth embodiment of the present invention.

Fig. 18 is a schematic illustration of a device which is used in a heating step in a seventh embodiment of the present invention.

Fig. 19 is a schematic illustration of a device used in a modification of the seventh embodiment.

Fig. 20 is a schematic illustration of a device which is used in a heating step of an eighth embodiment of the present invention.

Fig. 21a is a schematic illustration of a base plate and a pressing cover used in a ninth embodiment of the present invention in which cutting and melting are conducted simultaneously.

Fig. 21b is a schematic side elevational view of the base plate and the pressing cover which are brought together.

Figs. 22 and 23 are illustrations of a method for spherulizing the metal wires on the base plate in the ninth embodiment.

Fig. 24 is an illustration of the base plate of Figs. 22 and 23, on which the fine metal wires are spherulized, and a pressing cover used therein.

Figs. 25 and 26 are illustrations of a pressure to be used in the ninth embodiment.

Figs. 27 and 28 are illustrations of different examples of the base plate used in the present invention.

Fig. 29 is an illustration of a modification of the ninth embodiment in which three base plates are used in stack.

Fig. 30 is an illustration of a modification of the ninth embodiment in which the metal wires are beforehand prepared in a wire-like form to enhance the necessity for a cover.

[First Embodiment]

A first embodiment, which will be described with reference to Figs. 2A and 2B, is effective in cutting a fine wire of a high precision without allowing any slack of the fine wire. More specifically, in the method shown in Fig. 2A, a bundle of fine metal wires is enclosed in a sheath 8 of a resin such as vinyl chloride. The bundle wire sheath is then cut into pieces of a constant length and then the sheath of each piece is broken, whereby metal wire chips 6 of a predetermined length are obtained. This method, however, involves a risk in that, when a fine wire diameter or mass is too small, precision of the cutting length may be impaired due to bend or tear of independent wires in the sheath. Fig. 2B shows a method in which a multiplicity of metal wires 8 are laid to parallel and sandwiched between two tapes 4 and 5, and the sandwich structure is cut at a predetermined length. Metal wire chips 6 of a predetermined length are then obtained in the tape 4 separated in this method, at least one of the tapes should be an adhesive tape. The other tapes need not always be adhesive. The covering tapes may be a sheet of paper or the like. With this method, it is possible to obtain metal wire chips with an accurate cutting appearance having a wire cutting blade. The metal wire chips 6 thus obtained are arrayed on a crucible 1 made of a material which is not reactive with the metal of the wire chips, as

shown in Fig. 1. Fine metal spheres could be obtained with a high degree of uniformity in size, by heating these fine wire chips in the crucible.

Cutting of the metal wire into chips could be conducted with a very small error of ± 0.1 mm or less by a commercially available automatic cutting device. Fine metal wire chips cut at the predetermined length were placed at a spacing greater than a predetermined final value. In a crucible made of a material having a small volatility to the wire metal, e.g., graphite, and were heated in vacuum or an atmosphere of an inert gas. As a result of the heating, the wire chips were molten and became spheres due to action of the surface tension. After all the metal wire chips were molten, the spherical metal were cooled to solidify without losing their spherical shape, whereby the fine metal spheres as the product were obtained. Working Examples of the first embodiment are shown below.

Working Example 1

Copper wire of 0.1 mm dia. were cut into wire chips of 0.7 mm long, and the fine copper wire chips thus obtained were placed on a flat bottom of a ceramic crucible at a pitch of 8 mm or so, followed by heating at 1120 °C in a vacuum furnace.

The copper spheres thus obtained were measured. The spheres had a mean diameter of 0.22 mm, with the maximum and minimum diameters of 0.24 mm and 0.21 mm, thus proving a high degree of uniformity of the size.

Working Example 2

Ten gold wire of 48 μ m dia. were bundled and clad to a sheath of vinyl chloride as shown in Fig. 2A. A plurality of clad bundles of gold wire were chopped by an automatic cutter into pieces of 0.3 mm long. After the cutting, the sheath of vinyl chloride was removed and gold wire chips of an equal length were taken out. The gold wire chips thus obtained were laid in a graphite crucible having a flat bottom at a pitch of about 1 mm, and the crucible was put in a vacuum chamber for heating at 1080 °C by induction heating method.

About 6000 gold spheres thus obtained were sieved with a #100 mesh sieve. Fresh spheres size 125 μ m. All the gold spheres passed this sieve. The gold spheres were then screened through a sieve of #140 mesh (aperture size 108 μ m). Most of the gold spheres passed this sieve. Diameters of 100 spheres selected from about 6000 spheres were measured. The mean diameter was 117 μ m and the standard deviation was 1.8. From the results of the sieving and measurement, it is understood that the diameters of the gold

spheres produced by this Working Example falls within a very restricted range between about 111 and 123 μ m.

Working Example 3

18 (Gibson) gold wire of 25 μ m diameter were adhered to an adhesive tape of 18 mm wide in parallel and at a pitch of 1 mm, in a manner shown in Fig. 2B. A paper tape of the same width as the adhesive tape was adhered to the adhesive tape, such that the wire was sandwiched between the adhesive tape and the paper tape. This sandwich structure was sliced by an automatic slicer at a constant width of 0.65 mm. Thus, each slice of the sandwich structure had 18 gold wire chips of the constant length of 0.65 mm. The slices with the chips were placed to a graphite heater and heated at 800 °C in atmosphere to burn the tapes. Then, after changing the atmosphere to vacuum, the gold wire chips were heated to 1170 °C by induction heating. Numerous gold spheres with uniform size were thus obtained after removal of the residue of the burnt tapes. In Working Example 3, the heating was conducted in two stages. The first stage, which was conducted for the purpose of burning the tapes in atmospheric air at a low temperature, is not essential but is preferably adopted particularly in the case where the material metal has such a high reactivity as to react with the impurities in the tape metal and to avoid any reaction between such impurities and the crucible surface.

Diameters were measured on 180 samples selected from the gold spheres thus obtained. The result being shown in Fig. 3, it will be seen that the diameters of all the sample spheres ranged between 78 μ m and 84 μ m and the mean diameter is 80.1 μ m with a standard deviation of 1.7, thus proving high degree of uniformity of the sphere size.

Metal spheres formed by conventional mass-producing method have a wide size distribution. In order to select spheres of a specified range of size, therefore, it has been necessary to classify the spheres by, for example, sieving, so as to remove spheres which do not fall within the specified range of diameters. According to the first embodiment of the invention as described, it is possible to mass-produce, without requiring sieving, metal spheres with such a high degree of uniformity in size as to enable the spheres to be directly applied to use which strictly require high dimensional precision, e.g., bumps, simply by cutting fine metal wire into chips exactly at a constant length. Furthermore, there is no restriction in the composition and purity of the metal which are encountered in the production of bumps by plating, thus allowing a wide

selection of the metals and alloys in accordance with the nature or purposes of the spheres.

The present invention is basically intended for the production of metal spheres with high degree of uniformity of size. However, the invention can be applied to production of spheres of any desired size distribution, by providing a predetermined distribution of the cutting length.

[Second Embodiment]

The first embodiment is a very effective way to produce metal wire as a bump material in a precisely cut by a known cutting device having a constant-pitch feeding mechanism. The first embodiment is suitable for small-scale productions. In a second embodiment of the present invention which will be described hereinafter, a bare material of a soft metal such as gold, drawn to an ultra-fine wire of 50 microns or smaller diameter, is cut into a large quantity of chips of a constant length of 1 mm or less, preferably 0.5 mm or less, accurately and with a high precision of cutting length, by using means which avoid any possibility of contamination of impurities such as adhesive components or components of impurity material.

Obviously, an efficient production of fine metal wire chips by cutting requires a structurally sound cutting of ultra-fine metal wire or, if only one wire is to be cut, a cutting method which provides an extremely high cutting speed. The second embodiment is based upon the first-mentioned method, i.e., simultaneous cutting of a plurality of ultra-fine wires bundled or arrayed in parallel. When a sheath, adhesive or tapes are used over the entire length of the ultra-fine wire for fixing these wires in parallel, the materials of the sheath, adhesive or tapes are concurrently cut to require a troublesome work for removing these materials. In order to eliminate this problem, the second embodiment makes use of an adhesive or tape which are applied only to both longitudinal ends of the parallel ultra-fine wires, so that no fixing material is applied to intermediate portions of the ultra-fine wires.

This method, however, requires any cutting method which cuts the wires from one towards the other ends. Namely, since the parallel arrangement of the ultra-fine wires is maintained by the supports at both ends thereof, the array of the wires is fixed when the wires are cut at that one end. A similar problem is encountered when the thickness of the base plate of the base plate is insufficient. The base plate, therefore, should be used in a clean state without any fixer held on the upper surface thereof. In order to cut the ultra-fine metal wire into chips of a constant length while the wires are supported in such an unstable manner, it is desirable and effective that the cutting be conducted at

once at all points where the cutting is necessary.

The second embodiment, therefore, is a result of a study for establishing a method which enables the cutting of intermediate portions of ultra-fine metal wires at once at all points where the cutting is necessary. As a result of the study, the inventors have found that such an object is easily achieved by using a special cutting jig composed of a stack of cutting blades having disk-like or linear cutting edges. Namely, ultra-fine metal wires stretched as a flat base plate made of, for example, a hard rubber could be cut to a short wire into chips of the desired length by means of a cutting jig having cutting edges which are arranged linearly at a constant pitch corresponding to the length of the chips to be obtained.

In the embodiment, attention must be paid to the following points.

It is necessary that the degree of parallel of the ultra-fine wires held on the flat base plate has to be sufficiently high to minimize error of the cutting length which may occur when the wires are not parallel. The cutting precision also tends to be impaired due to, for example, deformation at the cut edge, when the ultra-fine metal wires are placed in two or more layers on the base plate. Therefore, it is preferable to stack to carry ultra-fine metal wires. The applied also to the case where a plurality of ultra-fine metal wires are bundled.

In this embodiment, it is necessary that all the cutting edges are simultaneously brought into contact with the portions of the single ultra-fine wire along the length of the wire, if there is any difference in the timing of cutting by different cutting edges of the ultra-fine metal wire, an undesirable spring when the wire is cut by the first cutting edge, so that subsequent edges cannot cut the wire precisely. It is, therefore, necessary that all the cutting edges are held at the constant level. When a cylindrical cutting jig is used, attention must be paid to keep the side of the jig strictly in parallel with the stretched ultra-fine metal wire. When a flat tabular cutting jig is used, it is necessary that the plate formed by the ends of the cutting edges is held in parallel with the upper surface of the base plate or, at least, that the direction in which the edges of the cutting jig are arrayed is parallel to the longitudinal direction of the ultra-fine metal wire to be cut.

As the first step of this embodiment, the desired number of the ultra-fine metal wires to be cut are arrayed on a flat base plate. The fixing of these wires is done by applying an adhesive, tapes or sheaths only to both ends of these wires. Thus, the fixing means is not at all applied to intermediate portions of the ultra-fine wires. Consequently, the fixing material is not caused in the ultra-fine wire

chips after the cutting, thus eliminating any undesirable effect which may otherwise be caused by impurities in the subsequent melting step.

Furthermore, since all the portions of the intermediate parts of the ultra-fine metal wire to be cut are cut simultaneously by a jig having a plurality of disk-like or linear cutting edges, it is possible to obtain a large number of ultra-fine metal wire chips of the constant length simply by arraying the ultra-fine metal wires and fixing them only at their both ends.

Preferably, the flat base plate on which the ultra-fine metal wires are laid is made of a material having a low structure and having a certain degree of elasticity, such as a hard rubber, plastic or so forth. The base plate made from such a material does not unnecessarily damage the cutting edges so that the cutting jig can stand a long use. Working Example 1

Fig. 4 is a perspective view schematically showing a cutting operation conducted in accordance with this embodiment. Gold wire of 30 μ m dia., used as the bare ultra-fine metal wire 1, were placed on a hard rubber plate serving as the base plate 3. These gold wires were fixed only at their both ends by means of adhesive tapes 2 bonded to the hard rubber plate. A cylindrical cutting jig 10, having a multiplicity of disk-like cutting edges 11 arrayed at a pitch of 0.65 mm, was rolled on the top surface of the hard rubber plate from one end of the hard rubber plate towards the other end, whereby ultra-fine gold wires on the hard rubber plate were cut at a length of 0.65 mm.

The gold wire chips after the cutting were placed in a graphite crucible as at not to contact each other, and were high-frequency heated, whereby gold spheres for use as bumps were obtained with a high degree of uniformity in size and without any impurity.

Working Example 2

The concept of Working Example 2 will be described with reference to Fig. 5. A plurality of small projections 6 were provided on both ends of a hard rubber plate used as the flat base plate 3. A continuous ultra-fine metal wire was stretched by being turned around the projections on alternating ends of the base plate 3, whereby a plurality of runs of the ultra-fine metal wires were arranged at a constant pitch. In this case, a gold wire having a diameter of 25 μ m was used as the ultra-fine metal wire. A small amount of adhesive was applied to the portions of the ultra-fine gold wire around the projections so as to temporarily fix the wire. A cutting jig 10 was used in which a multiplicity of razor blades 18 were arrayed such that cutting edges of the blade form a

flat plane. The cutting jig 10, while being held in horizontal position, was moved downwards over the hard rubber plate 3 on which the gold wires 1 were stretched, whereby the ultra-fine gold wires were cut at plurality portions over the entire length substantially simultaneously. The gold wire chips after the cutting were then laid in a graphite crucible having a flat bottom at a pitch of about 1 mm, and the crucible was put in a vacuum chamber for heating at 1080 °C by induction heating method.

Working Example 3

Referring to Fig. 6, a multiplicity of ultra-fine metal wires 1 (gold wire of 25 μ m dia.) were bundled and fastened together at their both ends. The bundle was laid on a polypropylene plate serving as a flat base plate 4 without any slack. Both ends of the bundle fastened by adhesive were fixed to the base plate 4 by means of adhesive tapes 2.

A cutting jig 10 which is the same as that used in Working Example 1, i.e., jig having disk-like edges 11 arrayed at a pitch of 1 mm, was rotated and moved towards the polypropylene plate on which the bundle of the ultra-fine metal wires was fixed.

The gold wire chips obtained through the cutting were taken by the same process as the first embodiment, whereby the gold spheres optimum for use as bumps were obtained.

Thus, in the second embodiment of the present invention, ultra-fine metal wire chips, suitable for use as the material of bumps used in, for example, TAD method, can be obtained in a very large lot without mixing of impurities. In consequence, the troublesome work for removing impurities of ultra-fine metal chips before melting is eliminated to enable a very efficient production of bumps.

[Third Embodiment]

This embodiment provides a cutting method in which metal wire chips of a constant length, which are to be cut into bump bumps, can be cut from the metal wire in a large lot by a cutting means which excludes any possibility of mixing of impurities such as components of adhesive or fixing material and which can supply the cut fine metal wire chips to a subsequent melting step without allowing these chips entangle with one another.

In a first cutting method used in this embodiment, a fine metal wire is fed through a guide 8 having a narrow inside diameter and, when the wire is fed out of the outlet end of the guide by a predetermined length, a cutting blade provided in the vicinity of the guide is advanced to cut the fine

metal wire.

In a second cutting method used in this embodiment, the fine metal wire is fed through a guide 8 having an inside diameter just for allowing a fine metal wire to pass therethrough and a guide Y having an inside diameter slightly greater than that of the guide 8, wherein the fine metal wire is advanced through the guide 8 is advanced at its leading end by the guide Y by a predetermined length, a relative movement is caused between these guides so that a shearing is effected by the opposing edges of both guides, whereby the fine metal wire is cut.

This embodiment is intended for cutting fine metal wire having diameters 50 μ m or smaller. The fine metal wire chips thus formed by cutting are arrayed in such a manner as not to be tangled with one another and are rolled to form spherical bumps. The cutting step, therefore, should not be considered alone but should be considered from the view point of ease of melting in the next step.

In the melting step, attention must be paid above all to exclude any impurity, not only impurities which tend to be mixed in the metal as the bump material but also impurities which tend to attach to the bump surface. Needless to say, such impurities should be removed before the metal chips are heated to a high melting temperature, rather than after the formation of the bump spines.

In the method of the first embodiment for example, fixing means such as tapes are used for fixing the fine metal wires, a cutting operation has to be conducted before the melting for removing impurity sources such as the tape pieces after the cutting of the wires into fine metal wire chips, unless such impurity sources are of a type which can completely be distinguished by burning during the heating. Such a cutting operation is extremely difficult to conduct. It is therefore highly desirable that the cutting step is completed without using the impurity sources such as tapes and adhesives. It is also necessary that the independent metal wire chips are brought to the melting step without being intertwined by one another. If a plurality of metal wire chips contacting one another are brought to the melting step, the melts of these chips will merge together to form large bumps which are practically unusable.

Thus, the third embodiment is mainly aimed at providing a cutting method for cutting fine metal wire in such a manner as to exclude mixing of impurities and, especially, to facilitate sorting of cutting of the metal wire chips leading to a receiver.

In order to achieve this aim, it is necessary that an independent fine metal wire, without any treatment, is cut at a high speed and the severed fine

metal chips are evenly received by a receiver. By momentarily moving the receiver, it is possible to avoid concentration of the wires to local portions on the receiver.

The following two methods are conceivable as the method of cutting independent fine metal wires. In a first method, a guide is used which has a needle-like bore of a small diameter just for allowing the fine metal wire to pass therethrough. The fine metal wire fed through this guide is cut by a cutting tool which is disposed in the close proximity of the outlet end of the guide. In a second method, the above-mentioned guide is used as a guide X, in combination with another guide Y having a bore slightly greater than the bore of the guide X. These guides are arranged to space each other and, when a fine metal wire fed through the guide X is received in the guide Y by a predetermined distance, a shearing is effected between the opposing edges of the guides thereby to shear the fine metal wire. The first method requires a cutting tool disposed on the outlet side of the guide. The cutting tool, preferably has a cutting blade of a very small thickness such as that of a razor since it is required to cut the wire into chips of an extremely small length. The material of the blade should be selected to enable the guide to stand a long use. In particular, in the second cutting method, it is preferred to use carbide or a hard alloy because the cutting is effected by the shearing caused by the sliding between the ends of two guides.

The fine bore of the guide should have a diameter which is just for allowing the fine metal wire to pass therethrough. The clearance between the fine metal wire and the wall of the bore depends on the kind of the metal but should be on the order of several μ m. The diameter of the bore in the guide Y, however, is preferably determined to be about twice the diameter of the fine metal wire, in order that the leading end of the fine metal wire, which may have been deformed by the preceding cutting, can be eased into the bore without being interrupted by the brim of opening of this bore.

The fine metal wire is fed at a constant in order that the leading end of the fine metal wire, which may have been deformed by the preceding cutting, can be eased into the bore without being interrupted by the brim of opening of this bore.

The cut wire chips are ejected separately and independently so that they can be delivered to the subsequent melting step in a good order.

Working Example 1

Fig. 7 is a schematic illustration of a cutting method used in the third embodiment of the invention. A gold wire of 30 μ m diameter was used as the bare ultra-fine metal wire 1. Ground ceramic rolls were used as feed rolls 19, 20. These feed rolls 19, 20 are driven by stepper motors (not shown) as at

to advance the fine metal wire 1 through a hole in a guide 3 to a position where cutting blade 5a, 5b are stationed. The guide 3 is made of ceramic, while wear-resistant blades were used as the cutting blades. The length of each lead effected by the lead rolls is controlled by a driving unit (not shown) so as to be equal to the length of the cut metal wire chips to be obtained. In this Working Example, the driving unit was set to feed the wire at a pitch of 0.8 mm.

In order to say, the cutting blades 5a and 5b are spaced apart from each other and the feed rolls are rotating to feed the fine metal wire 1. When one cycle of feed is completed, the cutting blades are advanced to perform one cycle of cutting operation and then set again at the standby position. After the feed rolls conduct the next cycle of the feeding operation, the cutting blades are actuated again to conduct the second cycle of the cutting operation. Cutting operation is thus conducted successively so that the cut metal wire chips are allowed to drop independently of one another.

In this Working Example, a graphite crucible with a flat bottom is placed at a position where it can receive the falling cut wire chips and the position of the crucible is momentarily shifted upon each receipt of a cut wire chip. The crucible in which the cut wire chips are placed can directly be put in a melting furnace, whereby bumps can be produced at a high efficiency.

In this Working Example, cutting is effected by a pair of cutting blades which pinch the wire from opposite sides thereof. This, however, is only illustrative and the cutting may be effected from one side of the wire by making use of a rotary blade.

Working Example 2

The concept of the second cutting method used in the third embodiment will be described with reference to Figs. 2a and 2b. This cutting method, for cutting a fine metal wire 1, employs feed rolls 2a, 2b and a guide 3 which are the same as those used in the first cutting method described in connection with Working Example 1. This Working Example features the use of a guide 4 in place of the cutting blades described under the guide 3 in Working Example 1. The fine metal wire 1 used in this Example had a diameter of 30 μ m and the fine bore in the guide 4 had a diameter of 25 μ m and the diameter of the bore in the guide 4 was 40 μ m. Both guides were made of ceramic.

As the first step, the fine metal wire 1 is threaded both through the guide 3 and the guide 4, as shown in Fig. 2a. Then, the lower guide 4 is laterally moved by 0.8 mm relative to the guide 3, so that the fine metal wire is cut by shearing. After the cutting, the guide 4 is moved to the initial position

and then the fine metal wire is fed by the feed rolls into the guide 4. As the fine metal wire is fed into the guide 4 by a predetermined length, the feed rolls are stopped automatically and then the guide 4 is laterally moved to cut the fine metal wire. By this method, a fine metal wire could be cut into chips with a high degree of precision of the cutting length.

Thus, according to the third embodiment, it is possible to obtain fine metal wire chips which are to be melted in low bumps used in TAB method. For example, in a large lot without allowing mixing of impurities, but withdrawing accuracy for a work for removing impurities in advance of the subsequent melting step, while avoiding melting of a plurality of molten metal chips into a large sphere, thereby offering a highly efficient production of bumps.

[Fourth Embodiment]

This embodiment employs a cutting method which is different from that used in the third embodiment and in which a blank fine metal wire of a soft metal such as gold, which is drawn to a very small diameter of 10 microns or less suitable for production of bumps, is cut into a large number of chips of the desired length, at a high frequency and a high precision of cutting length, by cutting means which includes any impurity such as components of ceramic or filling material, while preventing mutual entanglement of the cut fine metal chips.

Two types of cutting methods are used. In a first cutting method, the leading end of a gripper which grips an end of the fine metal wire is moved to extract the wire from a guide by a predetermined distance and, then, cutting device provided in the open proximity of the gripper is actuated to cut the fine metal wire.

In a second cutting method, a fine metal wire is extracted by a predetermined length from a guide by means of feed rolls which are arranged on the outer side of the guide and, thereafter, a cutting device disposed in the close proximity of the feed rolls is actuated to cut the fine metal wire.

This embodiment features a specific way of cutting, the cut metal wire chips are arranged in such a manner as not to interfere with one another and then delivered to the melting step to become spherical bumps. Thus, the cutting conditions should be considered not on the basis of the cutting operation alone but should be considered also from the view point of ease of the subsequent melting operation.

The embodiment, therefore, is aimed at providing a cutting method which meets the first requirement of solution of ridging of impurities and the

second requirement for prevention of entanglement of the cut metal wire chips. In such a manner as to facilitate the control of spacing of the cut metal wire chips taken on the subsequent melting step, it is necessary that an independent band the metal wire is cut bi-hydral and the cut metal wire chips thus formed successively be processed one by one.

A metal wire of an ordinary diameter can easily be cut into a multiplicity of chips of a constant length, by intermittently pushing the wire by feed rolls and shearing a cutting device in each interval of the feed. In case of a fine metal wire having an extremely small diameter, however, the leading precision feed tends to be impeded due to feeding of the wire pushed by the feed rolls. It has become clear that this problem can be overcome by extracting the wire through a guide. The following methods were found effective for intermittently extracting the metal wire at a constant pitch.

The first method employs a holding means such as a gripper which grips part or whole of the leading and portion of the fine metal wire which is to be severed. The holding means is moved away from the guide by a distance corresponding to the length of the metal wire chips to be severed, thereby extracting the fine metal wire. The second method employs feed rolls arranged at the outer side of the guide. The feed rolls are driven by, for example, stepper motors one step of which corresponds to the length at which the fine metal wire is to be cut. According to these methods, troubles such as bending of the fine metal wire, which is caused when the fine metal wire is fed by pushing forward, is eliminated. In addition, a tendency for the fine bore of the guide to be clogged with the fine metal wire is greatly suppressed.

Mechanisms for extracting a fine metal wire at a constant pitch are thus realized. The inventors have conducted a study to find a cutting method suitable for combination with the described leading method. In order to obtain a high precision of the cutting length, it is necessary that the cutting blades be actuated with the portion of the wire as near as possible to the cutting blades is fairly fixed of the wire is fixed in a position removed from the cutting blades, the fine metal wire is largely moved by the movement of the blade itself, with the result that the cutting precision is largely compromised. In addition, the feeding portion should be determined to be as close as possible to the end of the fine metal wire. Further it is preferred to grip an extreme end of the fine metal wire, which is going to be severed, at a constant position between the guide and the cutting blades. In such a case, the portion of the fine metal wire, which has been delivered by the gripper, is severed off the wire

and the gripper can grip a new portion of the wire which has not been severally affected by the previous gripping and cutting. Such an arrangement of the holding means, therefore, remarkably enhances the reliability of an automatic system which performs the method of this embodiment.

The fine metal wire to be cut is intermittently extracted from the outer side of the guide. The length of extraction in each extracting cycle corresponds to the length of the cut metal wire to be obtained. The extraction is conducted by the feed rolls or the holding means provided on the outer side of the guide. The cutting is conducted by cutting blades which are arranged in the close proximity of the feed rolls or holding means. Cutting operation suitable for mass-production was successfully executed without causing any bend of the fine metal wire in the guide bore or clogging of the bore by the wire, by virtue of the fact that the fine metal wire was extracted from the outer side of the guide rather than by being pushed into the guide bore.

Working Example 1

Figs. 2a and 2b schematically show basic construction of the embodiment. A gold wire of 30 μ m dia. was used as the fine metal wire 1. The fine metal wire 1 is extracted downward through a guide 3 made of quartz and having a bore of a diameter of 30 μ m. The leading end of the fine metal wire 1 reaches the space between the cutting blades 5a, 5b which are in expanded state just the space between holding members 3a, 3b which also are in the expanded state. A clamping device by 4a, 4b is disposed at the left side of the guide 3 so as to prevent the fine metal wire 1 moving laterally into the guide 3 (see Fig. 2a).

As the first step of the operation, the holding members 3a, 3b, made of ceramic, were brought together to pinch and fix the fine metal wire 1 from both sides thereof (see Fig. 2a). Subsequently, the clamping device 4a, 4b was moved apart and the holding members 3a, 3b gripping the fine metal wire 1 were moved downward by a distance d . Razor blades were used as the cutting blades 5a, 5b. The cutting blades 5a, 5b were so constructed that they moved vertically as a unit with the holding members 3a, 3b. Thus, the cutting blades 5a, 5b were moved laterally by the distance d as a result of the above-described downward movement of the holding members 3a, 3b (see Fig. 2b). As a result of the above-described operation, the fine metal wire was extracted by the length d from the guide 3.

The clamping device 4a, 4b was then closed and the cutting blades 5a, 5b were actuated to move horizontally to cut the fine metal wire 1 (see Fig. 2b).

The cutting blades 5a, 5b were moved to the waiting positions immediately after the cutting and the holding members 3a, 3b were moved apart so as to release the fine metal wire 1 thereby allowing the severed wire chip 10 to drop (see Fig. 2b). Finally, the holding members 3a, 3b and the cutting blades 5a, 5b were moved upward as a unit by a distance d (see Fig. 2a), then repeating the initial state shown in Fig. 2a. It is thus possible to successively sever wire chips of a constant length d by cyclically conducting the steps shown in Fig. 2a to 2b. Tests were conducted by employing different distances d , i.e., 0.3 mm, 0.5 mm and 0.8 mm. In each case, the cutting could be done with a small error within ± 0.1 mm.

Working Example 2

In Working Example 1 described above, the clamping device 4a, 4b has a role to prevent the fine metal wire from being laterally moved into or out of the guide when the cutting operation 5a, 5b which clamp the fine metal wire at the guide outlet are set to the releasing position. This role, however, may be performed by a suitable means other than the clamping device used in Working Example 1.

In Working Example 2, the guide 31 has a spiral bore so as to play the role of the clamping device. The holding members 3a, 3b and the cutting blades 5a, 5b were the same as those used in Working Example 1. According to this arrangement, a certain resistance is produced by the wall of the spiral guide 31 when the fine metal wire 1 is fed through the guide 31, so that the extracted fine metal wire is actuated at the extracted position. Consequently, cutting was effected with a high precision as in Working Example 1, despite the absence of the clamping device.

Working Example 3

Fig. 11 is a schematic illustration of the apparatus used in this Example. Hereinafter, a fine metal wire 1, 2 passes a guide 3a, 3b diameter holding members and 4a, 4b diameter cutting blades. Feed rolls 2a, 2b were placed on the outer side of the guide 3. The feed rolls 2a, 2b, made of ceramic and having a diameter of 3 mm, were placed at a position where it is 10 mm spaced from the outlet end of the guide 3. The feed rolls were driven by stepper motors which are not shown, so as to intermittently rotate the fine metal wire at a constant length from the outlet end of the guide 3. In this Working Example, the portion of the fine metal wire to be cut is automatically moved to the position of the fine metal wire, so that there is no need for the holding members 3a, 3b and the cutting blades 4a, 4b to be moved vertically. The feed rolls

rotate by an angle corresponding to one step so as to extract the leading and portion of the fine metal wire 1, while both the holding members 3a, 3b and the cutting blades 4a, 4b are in their spaced position. Thus, the holding members 3a, 3b are brought together to fix the end of the fine metal wire and then the cutting blades 4a, 4b are moved horizontally thereby cutting the fine metal wire 1. Cutting could be done by this method with a high degree of precision, when conducted on a gold wire of 30 μ m dia. at the fine metal wire 1 at a cutting length of 0.4 mm.

Working Example 4

The method of the fourth embodiment is for cutting an independent fine metal wire at a high precision. In order to improve the cutting efficiency, it is possible to combine a plurality of cutting elements for a plurality of independent wires so as to simultaneously process the wires in a parallel fashion. Fig. 10 shows an example of such a system. Fig. 10 shows an example of such a system, arranged for structurally cutting four metal wires. The guide 3 used in this Working Example is made of ceramic and has a split-type complementary groove which in cooperation defines a passage for the fine metal wire when these helms are brought together. The feed rolls 2a, 2b also are made of ceramic and are provided to guide the fine metal wire chiplets. The rolls are driven by stepper motors which are not shown so that four fine metal wires 1 are extracted at one by an equal length.

The holding members 3a, 3b, as well as the cutting blades 4a, 4b, can simultaneously act on the four fine metal wires. The feed rolls are rotated while the wires are fixed from the holding members and the cutting blades, thereby extracting the fine metal wire by a predetermined length. Then, the holding members are actuated to fix the ends of the fine metal wires, followed by activation of the cutting blades 4a, 4b for cutting the fine metal wires.

Gold wires of 30 μ m dia. were uniformly cut into wire chips of 0.4 mm long by the described method.

According to this embodiment, the metal wire can be cut precisely without causing the fine metal wire to contact any impurity. In addition, the cut wire chips can be taken out in a separated state, thus facilitating delivery to the subsequent melting step.

[Fifth Embodiment]

Materials of bumps are mainly not metals. Wire formed from a bump material is generally up

flexible that it is unilaterally bent by the force of gravity, making it difficult to handle. In order to enhance the precision of the cutting length, it is necessary that the severed metal wire be fed precisely at a predetermined pitch. It is, however, extremely difficult to precisely lead a fine wire of a small diameter having an extremely small diameter of several tens of microns and about 10 microns at the smallest.

The fifth embodiment has been accomplished in view of the above-described problem. Thus, the fifth embodiment provides a method which enables a metal wire to be cut efficiently and precisely into wire chips of a predetermined length and which is different from those used in the first to fourth embodiments.

The method of the fifth embodiment has the steps of: providing a first roll having a plurality of cutting edges formed at a constant circumferential pitch, a second roll conducted by the first roll, and a guide portion between the first and second rolls for cutting a fine metal wire; and rotating driving at least one of the first and second rolls so as to clamp and pull the fine metal wire into the gap between the first and second rolls, thereby cutting the fine metal wire by the cutting edges.

The second roll may have an outer peripheral surface region made of an elastic material.

In this embodiment, the fine metal wire guided by the guide portion is clamped by and pulled into the gap between both rolls, so that the wire can be precisely extracted even when it is highly flexible. In addition, it becomes possible to cut the fine metal wire precisely into metal wire chips of a predetermined length by designing the first roll such that the pitch of the cutting edges is equal to the cutting length. The second roll, when provided with peripheral surface region made of an elastic material, can grip and pull the fine metal wire with enhanced frictional force.

Working Example 1

The fifth embodiment of the present invention will be described in more detail with specific reference to Figs. 13 and 14. Fig. 13 is a schematic illustration of an arrangement for conducting cutting step for cutting a fine metal wire in the fifth embodiment, while Fig. 14 is a schematic enlarged view of rollers during cutting of a fine metal wire by the cutting arrangement shown in Fig. 13. In this embodiment a gold wire of 30 μ m diameter is used as the fine metal wire.

The cutting step for cutting a fine metal wire in the Working Example 1 is conducted by a cutting arrangement which includes feed rolls 2 for feeding forward the fine metal wire 30, a guide 4 made of quartz and having a bore of 30 μ m dia. and a

pair of rolls 5a, 5b arranged below the guide 4.

A movable cutting roll 2a (first roll) has a multiplicity of cutting edges 22 which are arranged at a constant circumferential pitch as shown in Fig. 13. The pitch of the cutting edges 22 is determined by the size of spherical bumps to be obtained and the diameter of the fine metal wire used as the metal wire. In this Working Example, the pitch of the cutting edges is set to be 0.25 mm, in order to form spherical bumps of 80 μ m diameter from a gold wire of 30 μ m in diameter.

The pressing roll (second roll) 2b has an outer peripheral surface region made of an elastic material provided by 23. This elastic material is used in order to increase the frictional attraction force as well as to easily and securely grasp the fine metal wire 30. The pressing roll 2b is provided with a cutting lead adjusting mechanism 24. This mechanism is adapted for adjusting the pressure of contact between the cutting roll 2a and the pressing roll 2b. The axial movement of the roll 2a, 2b (movement in the direction perpendicular to the drawing sheet of Fig. 13) may be as small as about 2 mm. The diameter of the fine metal wire is very small. The diameters of these rolls 2a, 2b may be about 30 mm or so.

In general, cutting of a fine metal wire into chips of a predetermined length by feeding the wire forward by feed rolls alone encounters with a problem is that the feed cannot be conducted in a high precision due to bend of the fine metal wire. The feed rolls 2 of Working Example 1 are intended to avoid bending the guide portion 4 with the fine metal wire 30 in the initial stage of the operation. Thus, the feed rolls 2 merely support the fine metal wire 30 and do not positively feed the same during operation of the apparatus. In this Working Example, the extraction of the fine metal wire 30 is effected by the pair of rolls 5a, 5b so as to be understood from the following description. Thus, the feed rolls 2 are not indispensable.

For cutting the fine metal wire 30 by the arrangement of Working Example 1, the leading end of the fine metal wire 30 is threaded through the gap between the feed rolls 2 and the feed rolls 2 are driven by, for example, stepper motors which are not shown, so that the fine metal wire 30 is introduced into the minute bore in the guide 4. The fine metal wire is thereafter guided into the gap between both rolls 5a, 5b through the guide 4. Subsequently, both rolls 5a, 5b are driven by a driving device which is not shown. Consequently, the fine metal wire 30 is clamped by and extracted into the gap between the rolls 5a, 5b. In this Working Example, the outer peripheral region of the pressing roll 2b is formed of an elastic material 23 so that the fine metal wire can be clamped and extracted without any risk of breakage. In addition,

wire chips having a certain length on a transport means with spacing thereon and a stop of irradiating each metal wire chip with a high-energy beam during metal wire transport process so that the metal wire chip is heated up to a temperature higher than the melting point of the metal wire chip to be melted.

In this embodiment, based on the above arrangement, each metal wire chip is irradiated with a high-energy beam to be melted so that it is heated up to a temperature higher than the melting temperature of the metal. The metal metal, which has a large surface tension, changes in shape to become spherical by itself, i.e., to become a free metal sphere.

Also, a light condenser means may be used to reduce the minimum spot diameter of the high-energy beam so that the free metal wire chip can be irradiated at a high efficiency.

Working Example

A working example of this embodiment will be described below with reference to the accompanying drawing. Fig. 30 is a schematic diagram of an apparatus used in this embodiment. In this working example, a gold wire chip (metal wire chip) having a wire diameter of 25 μ m, and a length of 0.53 mm was used and a gold sphere (free metal sphere) having a diameter of 80 μ m was manufactured.

The apparatus shown in Fig. 30 has a heat resistant turn table 2 for transporting metal wire chips 10, a motor (not shown) for driving the turn table 2, a high-energy beam irradiation unit 4 for irradiating each metal wire chip, a collecting container 6 for collecting the metal spheres 20 formed, and a guide 8 for guiding the metal spheres 20 on the turn table 2 into the collecting container 6. The turn table 2 is formed of a ceramic and has a circular shape and a diameter of about 300 mm. In this method, the heated region is smaller in comparison with other methods, and it is not necessary to turn the whole of the turn table 2 in ceramic. For example, only a doughnut-like portion on which metal wire chips are placed may be formed of a ceramic.

A high-energy source means (not shown) is used as a beam source for the high-energy beam irradiation unit 4 (e.g., a beam spot emitter). The high-energy beam irradiation unit may incorporate a light condenser device having a condenser lens or a condenser lens to further condense the high-energy beam. The object can be heated up to 2000°C at the maximum by the high-energy beam irradiation unit 4.

To form free metal spheres 20, metal wire chips 10 cut by a metal wire cutter (not shown) were first placed on the turn table 2, and the turn

table 2 was driven to move each metal wire chip 10 to a high-energy beam irradiation position. Next, the metal wire chip 10 was irradiated with the high-energy beam to be melted so that it was heated up to a temperature higher than the melting point of the metal. Ordinarily, metal metal has a large surface tension and can change in shape to a molten state to become spherical by themselves. Accordingly, the shape of the molten metal was changed into a spherical shape while it was being irradiated with the high-energy beam. The metal melted and formed into the spherical shape was moved out of the high-energy beam irradiation range by the turn table 2, and the next metal wire chip was moved to the high-energy beam irradiation range. The metal formed into the spherical shape was gradually cooled and solidified to be formed as a free metal sphere 20 having a diameter of 80 μ m. On the other hand, the next metal wire chip was irradiated with the high-energy beam. Thus, the metal wire chips placed on the turn table 2 were successively heated and melted. Finally, the metal spheres 20 thereby formed were made by the guide 8 to fall into the collecting container 6, thereby being collected.

If a high-energy beam is formed by condensation using a light condenser device having a lens or the like is used, each metal wire chip can be irradiated with the high-energy beam condensed. The metal wire chips could therefore be melted in a short time so that it may be heated at an improved efficiency by concentrated energy.

Then, according to the free metal sphere manufacturing method of this embodiment, the metal wire chip is only placed on the turn table, and the process thereafter automatically proceeds to the step of collecting the free metal sphere. The working efficiency and the mass-productivity can therefore be improved. Further, the apparatus for this working example may have, for example, a unit for cutting the metal wire to form wire chips or by one of regular intervals which unit is provided above the turn table of this embodiment. Surely, it is possible to continuously conduct the step of cutting the metal wire, the step of irradiating the cut metal wire chip, and the step of collecting the free metal sphere.

Also, the method of this embodiment can be applied for metals or alloys which have not been described. It is thereby possible to easily manufacture the metal spheres having a composition suitable for lamps at an improved efficiency. If the metal spheres are manufactured by using other metals, it is necessary to change the heating temperature and the turn table speed with respect to metals used, since the melting points differs with respect to the metals. Also, according to the present method, heating may be effected in a special gas

atmosphere in order to prevent chemical reaction of a high temperature.

In the above-described embodiment, a turn table is used as the high-energy beam source, but the present invention is not limited to this. Alternatively, a laser, an infrared radiation heater or the like may be used as the high-energy beam source. An infrared radiation unit using an infrared radiation heater is specifically suitable for melting a low-melting-point metal used for a soldering material, because the maximum temperature of the infrared radiation heater is about 1200°C.

Also, in the above-described embodiment, a turn table is used as the metal wire chip transport means, but the present invention is not limited to this, and a belt conveyor may alternatively be used. In this case, needless to say, the belt conveyor must be formed of materials superior in resistance to heat. For example, to form the belt conveyor, the belt may be formed of heat resistant metal chains, and a multiplicity of small ceramic trays may be mounted on the belt.

According to this embodiment, as described above, a free metal sphere can easily be manufactured by irradiating a metal wire chip with a high-energy beam so that the metal wire chip is melted and by utilizing the large surface tension of the molten metal. It is therefore possible to provide a free metal sphere manufacturing method which can be improved in working efficiency and, hence, is mass-productivity.

Other Embodiment

In the method of producing the metal spheres of the seventh and eighth embodiments, a free metal wire is cut into metal wire chips having a predetermined length, which have to be then arranged mutually one by one at equal spaces on a rotating turn or the like.

While there may be a variety of means available for arranging free metal chips, including the ones described above, it is desirable, in such a case, that the step of cutting the metal wire into chips and that of putting them into the metal spheres be, if possible, unified, depending on the case on which the free metal spheres are produced.

This embodiment has been made in view of the above situation. It provides a method of producing free metal spheres which helps to enhance the operational efficiency and which allows mass production with ease.

The method of producing free metal spheres in accordance with this eighth embodiment is characterized in that, after stretching the metal wire on the upper surface of a heat-resistant base plate on which recesses are formed, the stretched free

metal wire is heated to melt, thereby making it possible to effect the cutting of the free metal wire and the stretching thereof simultaneously to obtain the metal sphere.

It is desirable that the above-mentioned base plate be equipped with a number of recesses whose size is uniform at least in terms of the recess openings over which the free metal wire is stretched.

Further, it is desirable that the free metal wire be heated to melt after placing a heat-resistant pressure lid upon the upper surface of the above-mentioned base plate, on which the free metal wire is stretched.

In this embodiment with the construction described above, a free metal wire stretched on the upper surface of the base plate is heated to cut by action into metal chips having a length corresponding to the size of the recesses, and these metal chips obtained by action are retained on the recess bottoms so as to be solidified there by utilizing the surface tension inherent in molten metal. Afterwards, they are allowed to calmly cool off to solidify so as to be formed into free metal spheres.

Since the above-mentioned base plate has a number of recesses which are uniform in size and in the shape of the openings over which a metal wire is stretched, the free metal chips obtained by action have the same length, thus making it possible to mass-produce free metal spheres having the same size with ease.

Further, by heating the free metal wire to melt after placing the heat-resistant pressure lid upon the upper surface of the above-mentioned base plate, on which the free metal wire is stretched, any distortion of the metal chips, caused by the thermal expansion as a result of heating the free metal wire, can be prevented. Further, it is the case where a large number of openings are formed on the base plate, some variation occurs in terms of the time at which the action takes place at the different recesses, the free metal wire can be reliably heated for each recess.

Working Example

In the following, a working example of this embodiment will be described with reference to the accompanying drawing. Figs. 31A to 34, Fig. 31A) is a schematic diagram showing the base plate and the pressure lid used in an embodiment of this invention. Fig. 31B) is a schematic side view showing the metal wire placed on the base plate and with which Fig. 32 and 33 are diagrams illustrating methods of stretching (a) the metal wire on the base plate; and Fig. 34 is a schematic diagram showing the base plate on which the free metal spheres (a) are

stretched and the pressure lid when they are firmly attached to each other. In this working example, a gold wire (free metal wire) having a diameter of 25 μ m was used to produce gold spheres (free metal spheres) having a diameter of 80 μ m.

Formed on the heat-resistant base plate 10 shown in Figs. 31A) and 31B) are a number of grooves (recesses) 12 having a fixed width. It is desirable that the width of the groove 12 be formed of a heat-resistant material such as alumina or ceramics. The dimension of the base plate 10, which is not particularly limited, was 30 mm in length (A) and 80 mm in width (B). The section of each groove 12 had a semi-spherical configuration (the width across the opening of each groove 12 was 0.8 mm; the width E of each of protrusions 14 provided between the grooves 12 was 0.1 mm; and the depth H of each groove 12 was 0.1 mm). Further, the configuration of the groove 12 is not limited to any particular type; instead of a semi-spherical one, the configuration of the section of each groove 12 may be a square or a V-shaped one. When at section has a V-shaped configuration, however, the bottom portion thereof may be rounded at 0.05 mm radius or more. Further, it is desirable that the width E of the inter-groove protrusions 14 be as small as possible.

The width G of the opening of each groove is determined by the diameter of the free metal wire and the size of the free metal sphere to be produced in the case of this working example, the forming of the grooves with an accuracy of ± 0.1 mm in the size of their width results in the variation of about 10% or less regarding the length of the heated metal wire chips and the error in the radius when formed into metal spheres was approximately 2% or less, thus making it possible to produce uniform free metal spheres with high accuracy. Accordingly, when fusing a free metal wire described above, no great influence occurs on the accuracy in the metal sphere obtained no matter in which case of adjacent grooves a gold wire portion disposed just upon a groove protrusion 14 may drop. Further, a number of plate 10 were provided on both ends of the base plate 10, at a space substantially equal to the plate diameter, with each of the plate 10 on one end being arranged to have a position corresponding to another position defined between adjacent two plate disposed on the other end. By virtue of this arrangement, a free metal wire can be stretched substantially in parallel on the upper surface of the base plate 10.

The pressure lid 20, which was also made of a ceramic material, was placed on the base plate 10, thereby serving to fix the free metal wire 10 which was stretched over the groove 12. The surface of the pressure lid 20 facing the base plate 10 was machined to be flat. Further, in the pressure lid 20

were provided holes 22 corresponding to the plate 10. It is desirable that the gap between the base plate 10 and the pressure lid 20 when they are put together be as small as possible. The base plate 10 and the pressure lid 20 were heated so that the gap width ranged from 0 to 10 μ m and the free metal wire 10 was sandwiched between the base plate 10 and the pressure lid 20 thus heated, thereby fusing the free metal wire.

To produce free metal spheres, the free metal wire 10 was first stretched on the upper surface of the base plate 10 in such a manner that it extended perpendicular to the groove 12. In this working example, the free metal wire 10 was, as shown in Fig. 32, sequentially disposed between the plate 10 provided on both ends of the base plate 10, thereby stretching the free metal wire on the upper surface of the base plate 10. Further, as shown in Fig. 33, it is also possible to provide no plate on the base plate 10, arranging a plurality of the metal wire 10 in parallel, as the case where a plurality of the metal wire 10 are thus arranged, the employment of the pressure lid 20 for fixing the free metal wire 10 is of particular significance.

After stretching the free metal wire (gold wire) 10 on the base plate 10, the pressure lid 20 was placed on the base plate 10, fixing it by a fixing member 30 such as a clamp or a hinge, as shown in Fig. 34. In this condition, the base plate was put, for example, in an induction heater, heating the gold wire 10 to 1000°C. Simultaneously with its melting, the gold wire was cut by action into wire chips at the protrusions 14 between the grooves 12. The wire chips dropping into the groove 12. In this embodiment, the width G of the groove 12 was 0.8 mm, so that each of the gold wire chips was 0.8 mm long. Thus, the gold wire chips obtained by the action were arranged in the groove, at an appropriate interval (approximately equal to the diameter of the plate 10).

Generally, molten metal has a large surface tension, so that, when a gold wire chip heated to a temperature not lower than its melting point, it tends to become spherical of itself when in a molten state. Accordingly, a free metal sphere could be produced merely by melting a metal piece having a mass identical to that of the metal sphere to be obtained and by allowing it to calmly cool off to solidify.

Accordingly, the metal wire chips arranged at fixed spaces in the groove 12 melted in the furnace and were formed into free metal spheres of a uniform size. Finally, the base plate 10 was taken out of the furnace and was allowed to cool off slowly, thereby causing the metal spheres having the size desired.

In the method of producing free metal spheres of this embodiment, the step of cutting the

free metal wire and that of melting the metal wire chips can be unified, so that the operation of arranging the metal wire chips after the cutting is not necessary, thus enhancing the operational efficiency in the process of producing free metal spheres. Further, by heating the free metal wire 10 to melt and forming them long, an improvement could be obtained in terms of mass-productivity.

Further, this embodiment adopts a heat-resistant material for the base plate 10 and the pressure lid 20, which means mass production, these components can be used semi-permanently.

Figs. 25 and 26 show other examples of the pressure lid used in this embodiment. The pressure lid 25 shown in Fig. 25 had recesses 24 with a width F of 0.2 mm and a depth G of 0.1 mm, which recesses were formed in three sections corresponding to the protrusions 14 between the grooves 12 of the base plate 10. In a case where the pressure lid 20s was formed in this way, no mechanical fitting was needed regarding the surface of the pressure lid portions extended between the recesses 24, thus facilitating the machining of the pressure lid 20s.

The pressure lid 20s shown in Fig. 26 was formed such that the surface portion facing the base plate 10 had an undulated configuration. This comes to the surface 26 of the undulation had a configuration corresponding to the groove 12 of the base plate 10. When the pressure lid 20s shown in Fig. 26 was used, the free metal wire was pressed downwards, during the heating operation, at the respective central portions of the groove 12 by the pressure lid 20s, so that the free metal wire could be reliably cut, at the time of heating, at the protrusions 14, thereby unifying the size of the metal wire chips obtained by the action.

Figs. 27 and 28 show other examples of the base plate used in this embodiment. The base plate 10s shown in Fig. 27 was characterized by protrusions 16, which were provided in the groove 12 of the base plate 10s shown in Figs. 27 and 28, thereby dividing the groove 12 into small chambers 12s having a length J of 4 mm. The thickness L of the protrusions 16 was 1 mm. The base plate 10s shown in Fig. 28 was characterized in that, instead of grooves, it had holes 18 having a diameter M of approximately 4 mm. When the base plate shown in Fig. 27 or 28 was used, the free metal wire chips obtained by heating a free metal wire dropped into the small chambers 12s or the holes 18, one chip into one chamber or one hole, so that no two or more metal wire chips were allowed to melt together, thus preventing any large-sized defective from being produced. Thus, by using the base plate shown in Fig. 27 or 28, an improvement could be obtained in terms of yield.

Although the above embodiment has been de-

As described above, this invention makes it possible to efficiently produce fine metal spheres having a uniform size and a satisfactory composition and involving no limitations in terms of purity and composition, so that the method of this invention can be applied to the production of the metal spheres of a uniform size to be used as burners required in the field of semiconductor packaging.

Claims

1. A method of producing fine metal spheres with a high degree of uniformity in size, comprising the steps of: forming metal wire chips by cutting a fine metal wire at a constant length and heating said metal wire chips to a temperature above the melting point thereof so as to melt said metal wire chips, thereby spheroidizing said metal wire chips.
2. A method according to Claim 1, wherein said step for forming said metal wire chips by cutting includes the steps of: arranging a plurality of ultra-fine metal wire chips in parallel on a flat base plate; and cutting said ultra-fine metal wire chips by a cutting fly having cutting edges which are arranged at a constant pitch.
3. A method according to Claim 1, wherein said step for forming said metal wire chips by cutting includes stretching, when a fine metal wire chip is fed by a predetermined length out of the outlet end of a guide having a fine internal bore, a cutting device which is arranged in the close proximity of said outlet end of said guide.
4. A method according to Claim 1, wherein said step for forming said metal wire chips by cutting includes the steps of: preparing a guide X having a fine internal bore which allows the fine metal wire to pass therethrough, and a guide Y having a fine internal bore of a diameter greater than that in said guide X, so that said internal bore of said guide Y, causing a relative movement between said guide X and Y so as to shear the fine wire into wire chips; arranging the wire chips so that the wire chips are not in contact with each other; and heating the wire chips to form them into the soft metal spheres or soft alloy spheres.
5. A method according to Claim 1, wherein said step for forming said metal wire chips by cutting includes the steps of: holding the end of said fine metal wire emerging from the outlet

end of a guide by a holding device; moving said holding device to extend said fine metal wire from said guide by a predetermined length; and cutting said fine metal wire by a cutting device which is disposed in close proximity of said holding device.

6. A method according to Claim 1, wherein said step for forming said metal wire chips by cutting includes the steps of: extracting said fine metal wire by a predetermined length out of a guide by means of lead rolls arranged on the outlet side of said guide, and cutting said fine metal wire by means of a cutting device disposed in close proximity of said lead rolls.
7. A method according to Claim 1, wherein said step for forming said metal wire chips by cutting includes the steps of: arranging a cutting device having a fine roll provided with a plurality of cutting edges arranged at a predetermined circumferential pitch, a second roll for contacting said first roll, and a guide portion provided between said first roll and said second roll, and driving at least one of said first roll and said second roll so as to clamp and lead said fine metal wire into the gap between said first and second rolls, thereby cutting said fine metal wire by said cutting edges.
8. A method according to Claim 7, wherein said second roll has an outer peripheral surface region formed of an elastic material.
9. A method according to Claim 1, wherein the step of heating said metal wire chips of the constant length includes arranging, in a conveyor means, said metal wire chips in a spaced state each other, and conveying said metal wire chips through a heating means, thereby heating said metal wire chips to a temperature above the melting point thereof so as to melt said metal wire chips.
10. A method according to Claim 8, wherein a lid is provided on the lower end of said second roll.
11. A method according to Claim 1, wherein the step of heating said metal wire chips of the constant length includes arranging, in a conveyor means, said metal wire chips in a spaced state each other, and conveying said metal wire chips through a heating means, thereby heating said metal wire chips to a temperature above the melting point thereof so as to melt said metal wire chips.
12. A method according to Claim 1, wherein the

step of heating said metal wire chips of the constant length includes arranging, in a conveyor means, said metal wire chips in a spaced state each other, and irradiating said metal wire chips with a high-energy beam while said metal wire chips are being conveyed, thereby heating said metal wire chips to a temperature above the melting point thereof so as to melt said metal wire chips.

13. A method according to Claim 13, wherein said metal wire chips are irradiated with high-energy beam which has been condensed through a light condensing means.
14. A method of producing fine metal spheres, comprising the steps of: providing a fine metal wire on the top surface of a heat-resistant base plate having a recess, and heating the stretched fine metal wire to a temperature above the melting point so as to melt said fine metal wire, thereby simultaneously stretching and spheroidizing of said fine metal wire.
15. A method of producing fine metal spheres according to Claim 14, wherein said base plate has a plurality of said recesses, at least the openings of said recesses over which said fine metal wire is stretched having an equal size.
16. A method of producing fine metal spheres according to Claim 14 or 15, wherein said fine metal wire is heated and melted after a pressing cover is placed on the top surface of said base plate on which said fine metal wire is stretched.

Amended claims

1. (Cancelled)

2. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: arranging a plurality of fine wires made of a soft metal or soft alloy, each of which wires has a diameter of not more than 100 μm , in parallel on a flat base plate; cutting said fine wire into wire chips by a cutting fly having cutting edges which are arranged at a constant pitch; arranging the fine wire chips so that the wire chips are not in contact with each other; heating the wire chips to form them into said soft metal spheres or soft alloy spheres.
3. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: stretching a soft metal or soft alloy fine wire of not more than 100 μm in diameter by a predetermined length out of a guide by means of lead rolls arranged on the outlet side of said guide; cutting said fine wire into fine wire chips by means of a cutting device disposed in close proximity of said lead rolls; arranging the fine

wire chips by completing the steps of: leading a fine wire having a diameter not more than 100 μm by a predetermined length out of the outlet end of a guide having a fine internal bore; cutting said fine wire into fine wire chips by actuating a cutting device arranged in the close proximity of said outlet; arranging the fine wire chips so that the fine wire chips are not in contact with each other; and heating the fine wire chips to form said fine wire chips into said soft metal spheres or soft alloy spheres.

4. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: disposing both a guide X having a fine internal bore which allows the fine soft metal or alloy wire of not more than 100 μm in diameter to pass therethrough and a guide Y having a fine internal bore of a diameter greater than that of said guide X so that said internal bore of said guide Y are aligned with each other; inserting said fine wire through said bore of the guides X and Y and the end of the wire is received by a predetermined length in said bore of said guide Y, causing a relative movement between said guide X and Y so as to shear the fine wire into wire chips; arranging the wire chips so that the wire chips are not in contact with each other; and heating the wire chips to form them into the soft metal spheres or soft alloy spheres.

5. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: holding the end of a soft metal or alloy wire of not more than 100 μm in diameter by a holding device; moving the holding device to extend said fine wire from a guide by a predetermined length; cutting said fine wire into fine wire chips by a cutting device disposed in close proximity of said holding device; arranging the fine wire chips so that the fine wire chips are not in contact with each other; and heating the fine wire chips to form them into the soft metal spheres or soft alloy spheres.

6. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: extracting a soft metal or soft alloy fine wire of not more than 100 μm in diameter by a predetermined length out of a guide by means of lead rolls arranged on the outlet side of said guide; cutting said fine wire into fine wire chips by means of a cutting device disposed in close proximity of said lead rolls; arranging the fine

wire chips so that the fine wire chips are not in contact with each other; and heating the fine wire chips to form them into the soft metal spheres or soft alloy spheres.

7. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: arranging a cutting device having a fine roll provided with a plurality of cutting edges disposed at a predetermined circumferential pitch, a second roll in contact with said first roll, and a guide portion for guiding a fine wire between said first and second rolls; driving at least one of said first roll and said second roll so as to clamp and tract a fine soft metal or soft alloy wire of not more than 100 μm in diameter into the gap between said first and second rolls to thereby cut said fine wire into fine wire chips by said cutting edges; arranging the fine wire chips so that the fine wire chips are not in contact with each other; and heating the fine wire chips to form them into the soft metal spheres or soft alloy spheres.
8. (After amendment) A method according to the claim 8, wherein the outer periphery of said second roll is formed of an elastic material.
9. (Cancelled)
10. (Cancelled)
11. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: preparing soft metal or alloy fine wire chips each having a predetermined length and having a diameter not more than 100 μm ; arranging the fine wire chips in a spaced state each other; and conveying said fine wire chips through a heating means to thereby heat said wire chips to a temperature above the melting point thereof so as to melt said wire chips.
12. (Cancelled)
13. (Cancelled)
14. (After amendment) A method of producing soft metal spheres or soft alloy spheres, characterized by completing the steps of: stretching a soft metal or alloy fine wire of not more than 100 μm in diameter on the top surface of a heat-resistant base plate having a recess at said top surface, and heating the stretched fine wire to a temperature above the melting point so as to melt said fine wire so that the cutting

and spheroidizing of the fine wire are effected simultaneously.

15. (After amendment) A method according to claim 14, wherein said base plate has a plurality of said recesses, at least the openings of the recesses over which the fine wire having a diameter not more than 100 μm is stretched being made to have an equal size.
16. (After amendment) A method according to the claim 14 or 15, wherein said fine wire is heated and melted after a pressing cover is placed on the top surface of said base plate on which said fine wire having a diameter not more than 100 μm is stretched.

FIG. 1

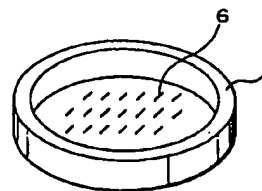


FIG. 2A

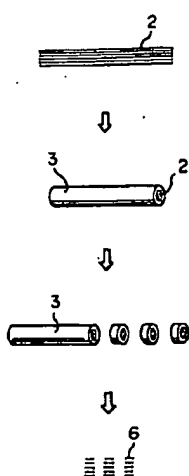


FIG. 2B

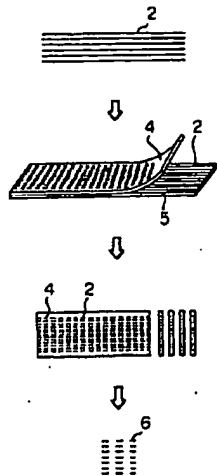


FIG. 3

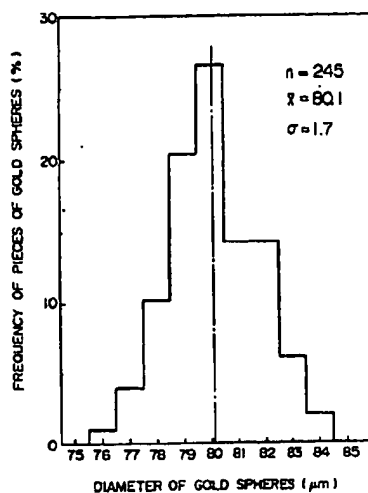


FIG. 4

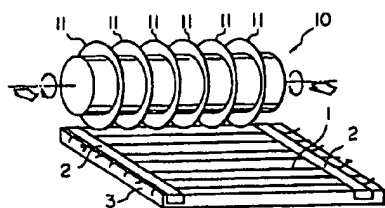


FIG. 5

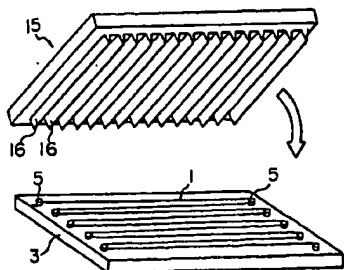
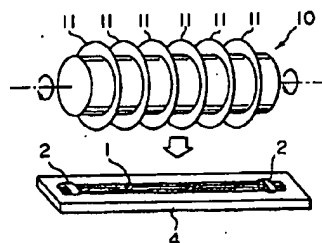
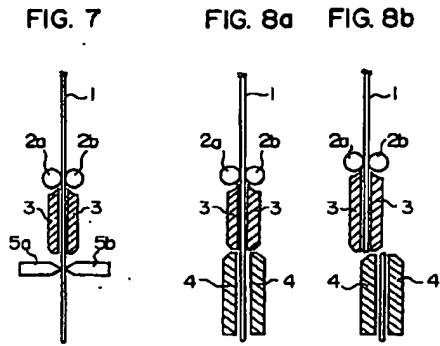


FIG. 6





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FIG. 10

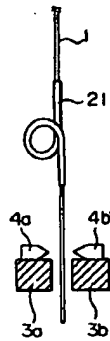
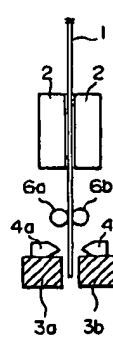
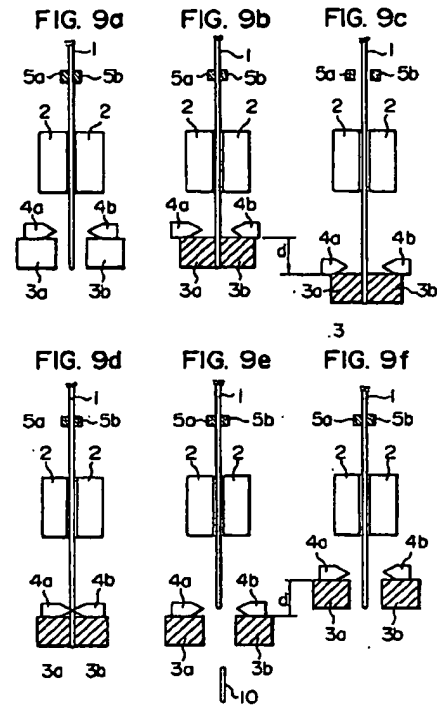


FIG. 11

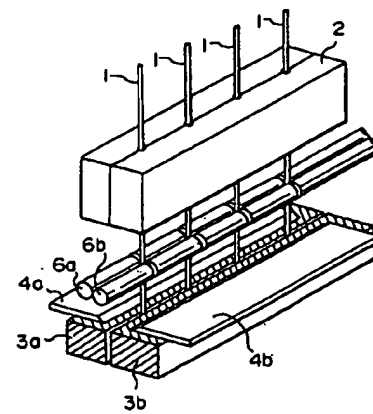


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FIG. 12



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FIG. 13

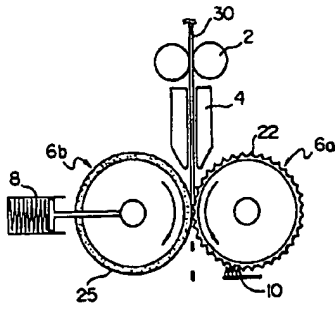
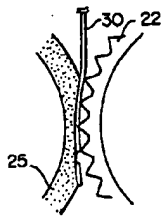


FIG. 14



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FIG. 15

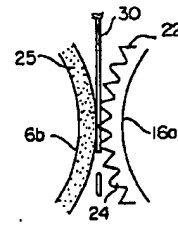
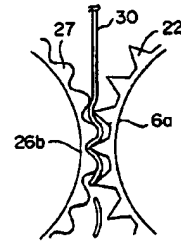
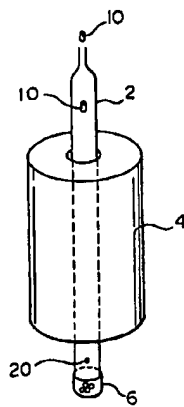


FIG. 16



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FIG. 17



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FIG. 18

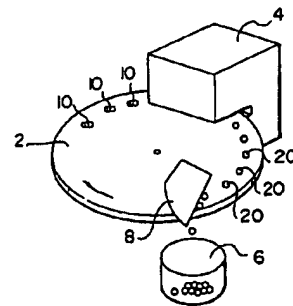
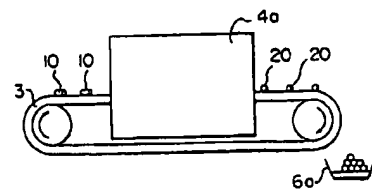
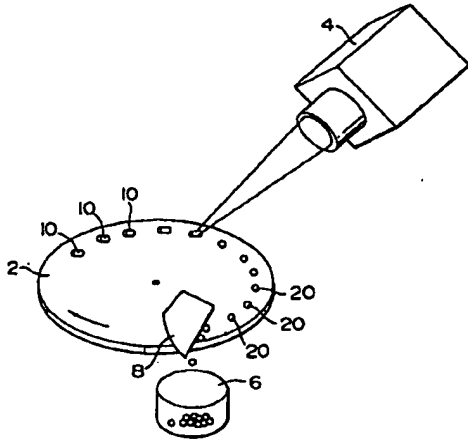


FIG. 19



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FIG. 20



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FIG. 22

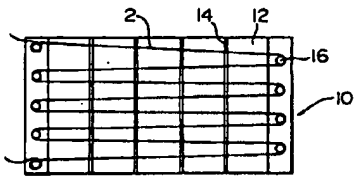
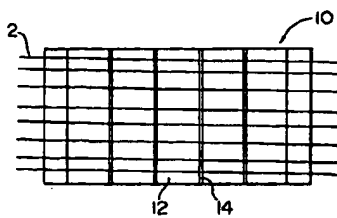


FIG. 23



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FIG. 21A

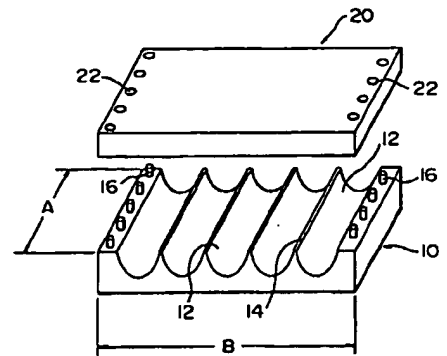
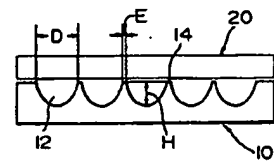


FIG. 21B



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FIG. 24

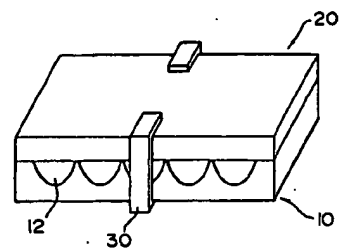
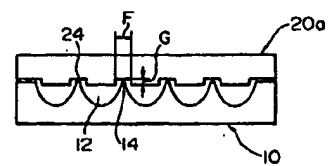


FIG. 25



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FIG. 26

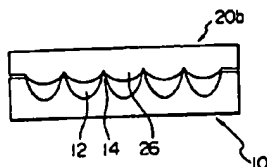


FIG. 27

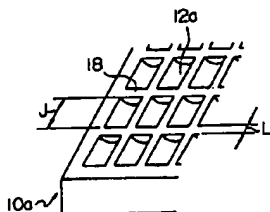


FIG. 28

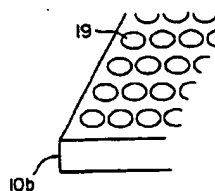


FIG. 29

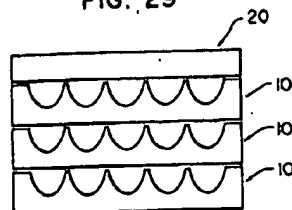
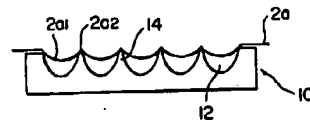


FIG. 30



INTERNATIONAL SEARCH REPORT

Document Number: PCT/JP90/01591

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6. DATE OF BIRTH (month, day, year) (1900)

BP 0 457 000 A1

International Application No. PCT/JP90/01591

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FURTHER INFORMATION CONTAINED FROM THE SECOND SHEET		
	June 27, 1966 (27. 06. 66), (Family: none)	
Y	JP, A, 60-5804 (Tanaka Kikinsaku Kogyo K.K.), January 12, 1965 (12. 01. 65), (Family: none)	2-13
Y	JP, U, 64-49333 (KCC Corp.), March 27, 1969 (27. 03. 69), (Family: none)	3
Y	JP, U, 64-55929 (Mitsubishi Steel Co., Ltd.), June 2, 1961 (02. 06. 61), (Family: none)	3

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 The international search report has not been established in respect of certain claims under Article 17(2) of the following reasons:
☐ Claim numbers: because they relate to subject matter not reported to be searched by this Authority, namely:
☐ Claim numbers: because they relate to parts of the international application that do not comply with the prescribed requirements in such a manner that no meaningful examination search can be carried out, specifically:
☐ Claim numbers: because they are dependent claims and are not drafted in accordance with the wording and legal character of PCT Rule 13.6.

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☐ As all required additional search fees were timely paid by the applicant, the international search report covers all identifiable claims of the international application.
☐ As only some of the required additional search fees were timely paid by the applicant, the international search report covers only those claims of the international application for which fees were paid, specifically claims:
☐ No required additional search fees were timely paid by the applicant. Consequently, the international search report is restricted to the claims first mentioned in the claims; it is restricted to claim numbers:
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FURTHER INFORMATION CONTAINED FROM THE SECOND SHEET		
A	JP, B1, 26-5610 (Kazuhiko Ogawa, Gentaro Matsumura), September 21, 1951 (21. 09. 51), (Family: none)	14-16
A	JP, B1, 41-11522 (H.V. Philipe, Gloeilampenfahrlaken), June 27, 1966 (27. 06. 66), (Family: none)	14-16
A	JP, A, 60-5804 (Tanaka Kikinsaku Kogyo K.K.), January 12, 1965 (12. 01. 65), (Family: none)	14-16

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☐ Claim numbers: because they relate to subject matter not reported to be searched by this Authority, namely:
☐ Claim numbers: because they relate to parts of the international application that do not comply with the prescribed requirements in such a manner that no meaningful examination search can be carried out, specifically:
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☐ No required additional search fees were timely paid by the applicant. Consequently, the international search report is restricted to the claims first mentioned in the claims; it is restricted to claim numbers:
☐ As all available claims must be searched without effect pending an additional fee, the International Searching Authority did not search any of the additional fees.
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FURTHER INFORMATION CONTAINED FROM THE SECOND SHEET		
	September 16, 1977 (16. 09. 77), (Family: none)	
Y	JP, A, 63-111101 (Daido Steel Co., Ltd.), May 16, 1968 (16. 05. 68), (Family: none)	9, 10
Y	JP, B1, 28-3974 (Isehaft mbs.), August 17, 1953 (17. 08. 53), (Family: none)	12
Y	JP, A, 63-33507 (Mitsubishi Metal Corp.), February 13, 1968 (13. 02. 68), (Family: none)	12, 13

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 The international search report has not been established in respect of certain claims under Article 17(2) of the following reasons:
☐ Claim numbers: because they relate to subject matter not reported to be searched by this Authority, namely:
☐ Claim numbers: because they relate to parts of the international application that do not comply with the prescribed requirements in such a manner that no meaningful examination search can be carried out, specifically:
☐ Claim numbers: because they are dependent claims and are not drafted in accordance with the wording and legal character of PCT Rule 13.6.

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 The International Searching Authority found multiple inventions in the international application as follows:
☐ As all required additional search fees were timely paid by the applicant, the international search report covers all identifiable claims of the international application.
☐ As only some of the required additional search fees were timely paid by the applicant, the international search report covers only those claims of the international application for which fees were paid, specifically claims:
☐ No required additional search fees were timely paid by the applicant. Consequently, the international search report is restricted to the claims first mentioned in the claims; it is restricted to claim numbers:
☐ As all available claims must be searched without effect pending an additional fee, the International Searching Authority did not search any of the additional fees.
☐ The additional search fees were submitted by applicant's process.
☐ No process accompanied the payment of additional search fees.

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